

Supporting information

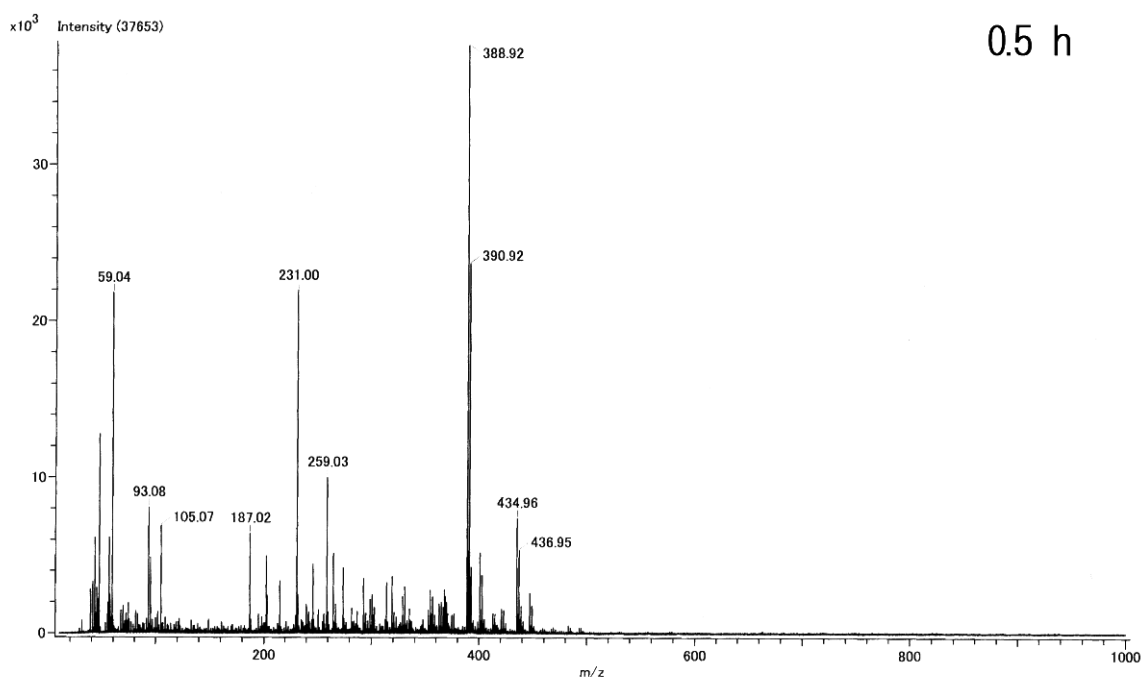
Photochemical and Ga₂O₃-photoassisted decomposition of the insecticide Fipronil in aqueous media with UVC radiation

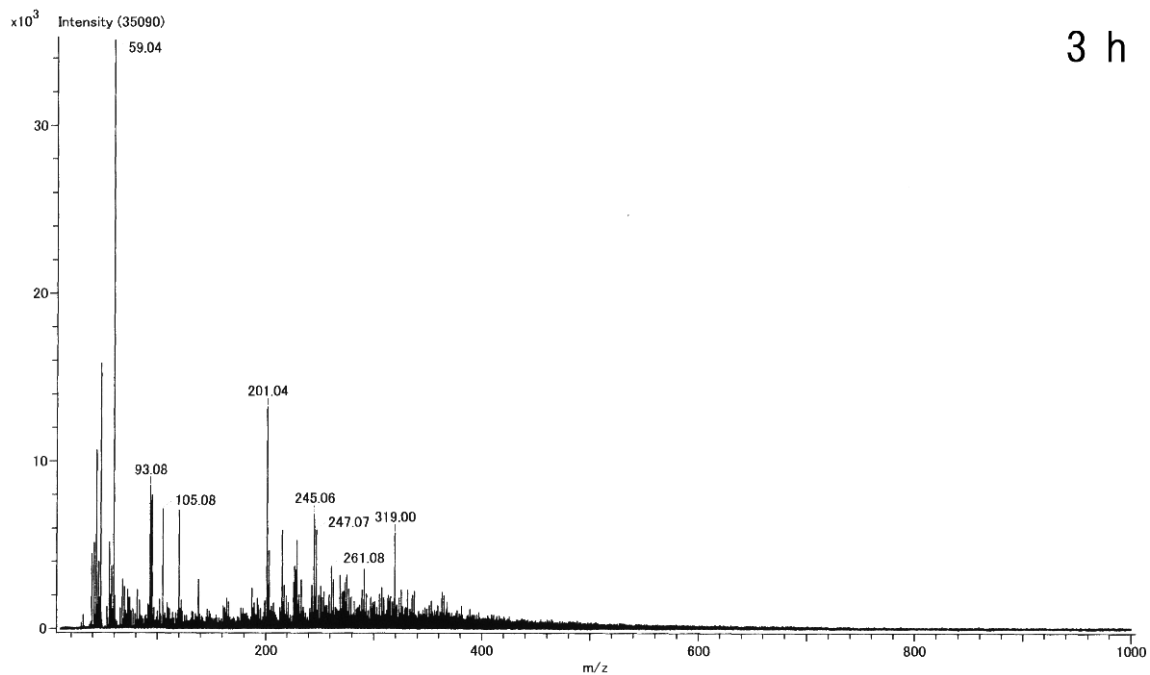
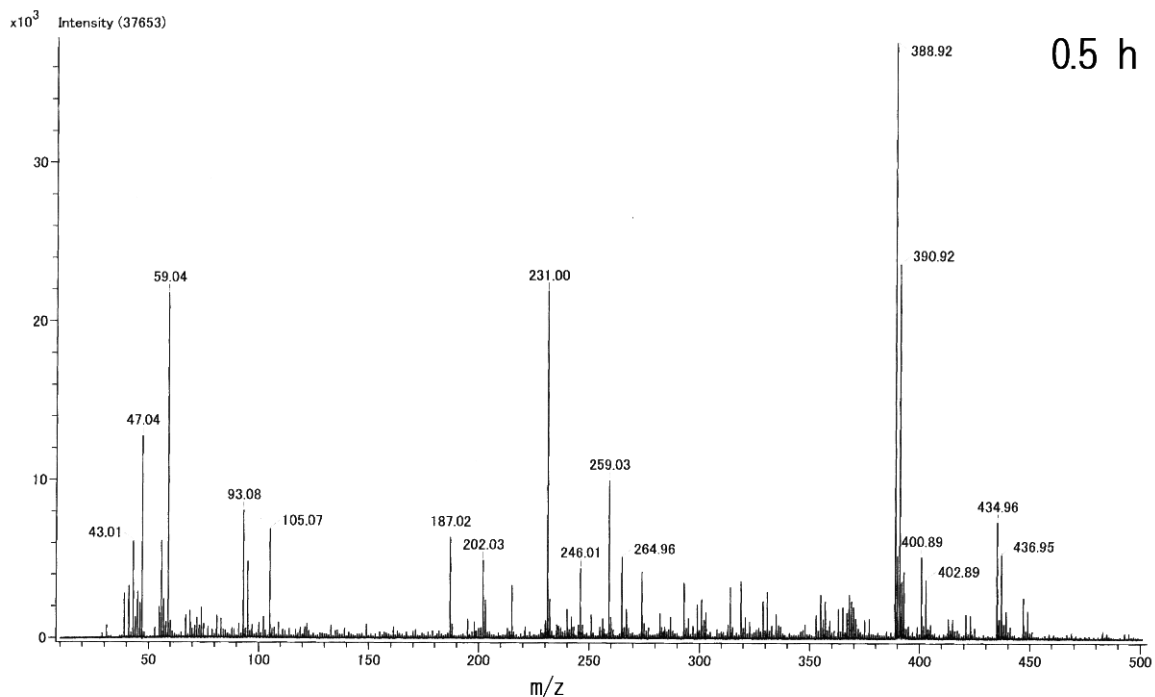
**Hisao Hidaka,^{a*} Tohru Tsukamoto,^a Yoshihiro Mitsutsuka,^a Takeji Takamura,^b
and Nick Serpone^c**

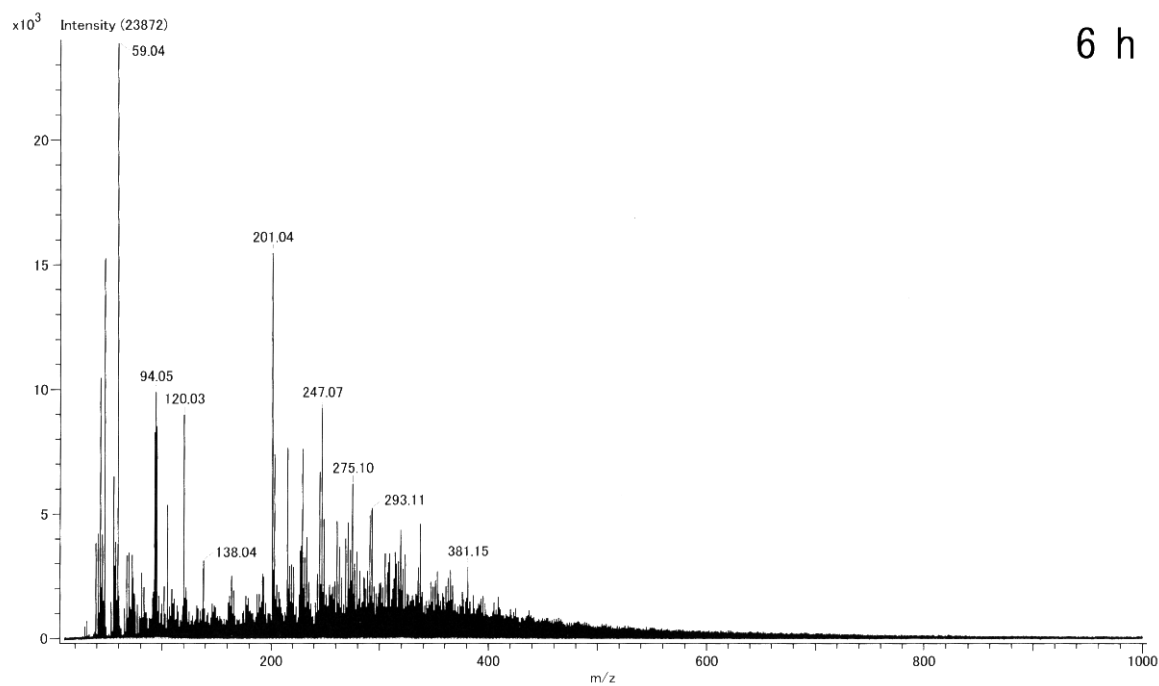
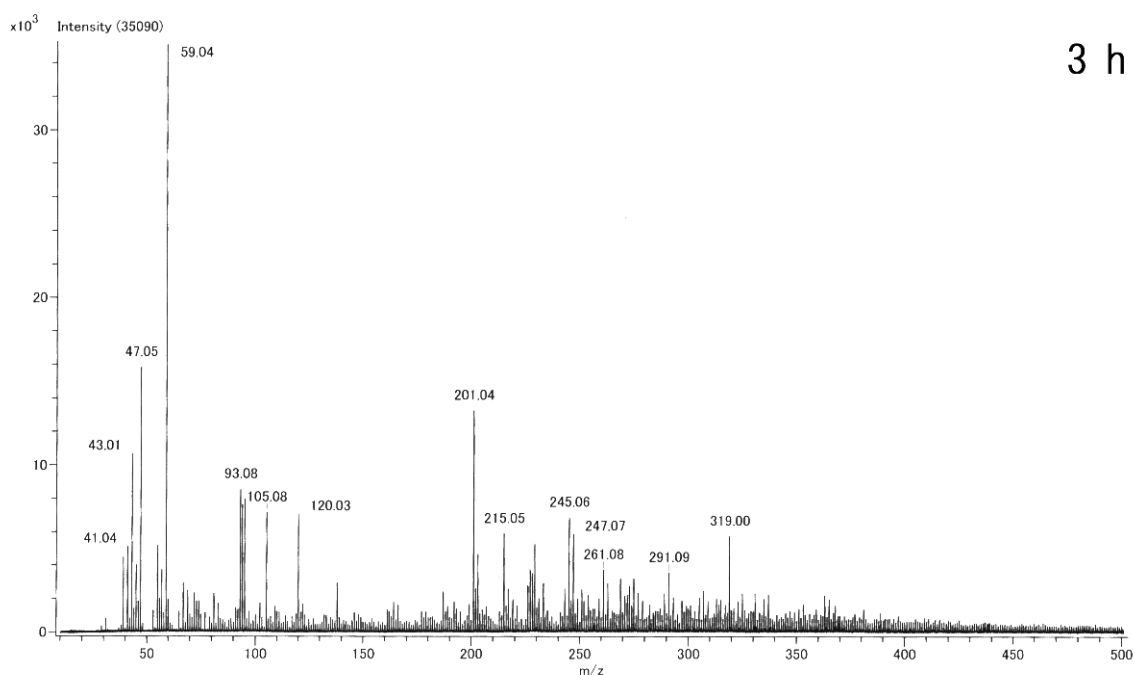
^a Department of Chemistry, Meisei University, 2-1-1 Hodokubo, Hino-shi, 191-8506, Tokyo, Japan

^b Department of Chemistry, Kanagawa Institute of Technology, 1030, Shinoogino, Atsugi, Kanagawa 345-0292, Japan

^c PhotoGreen Laboratory, Dipartimento di Chimica, Università di Pavia, via Taramelli 12, Pavia 27100, Italy







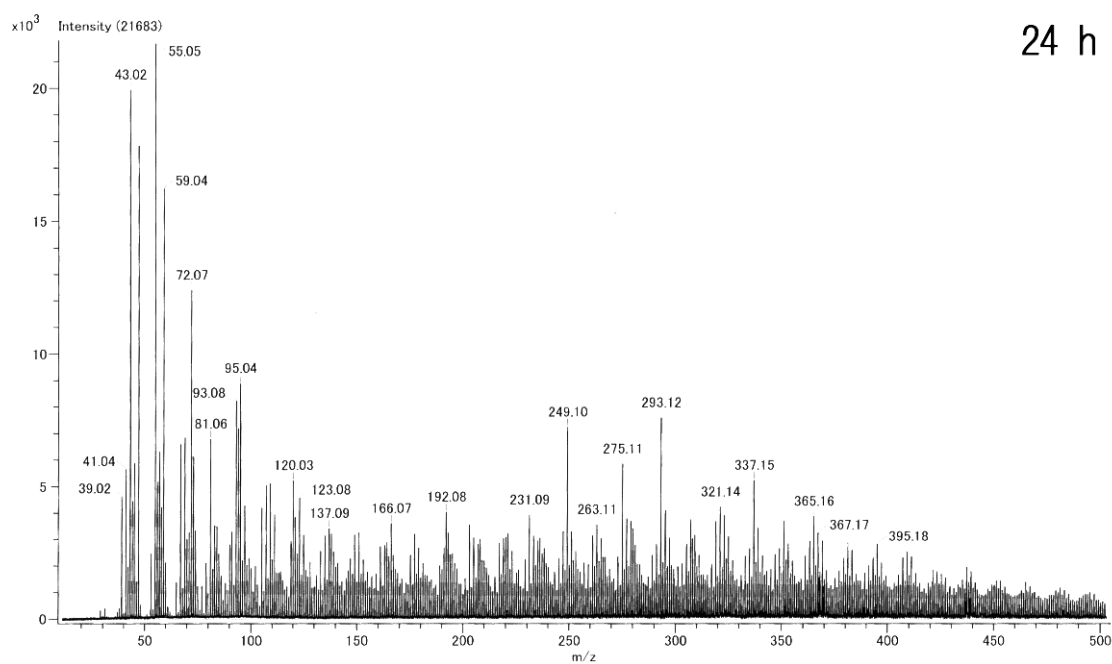
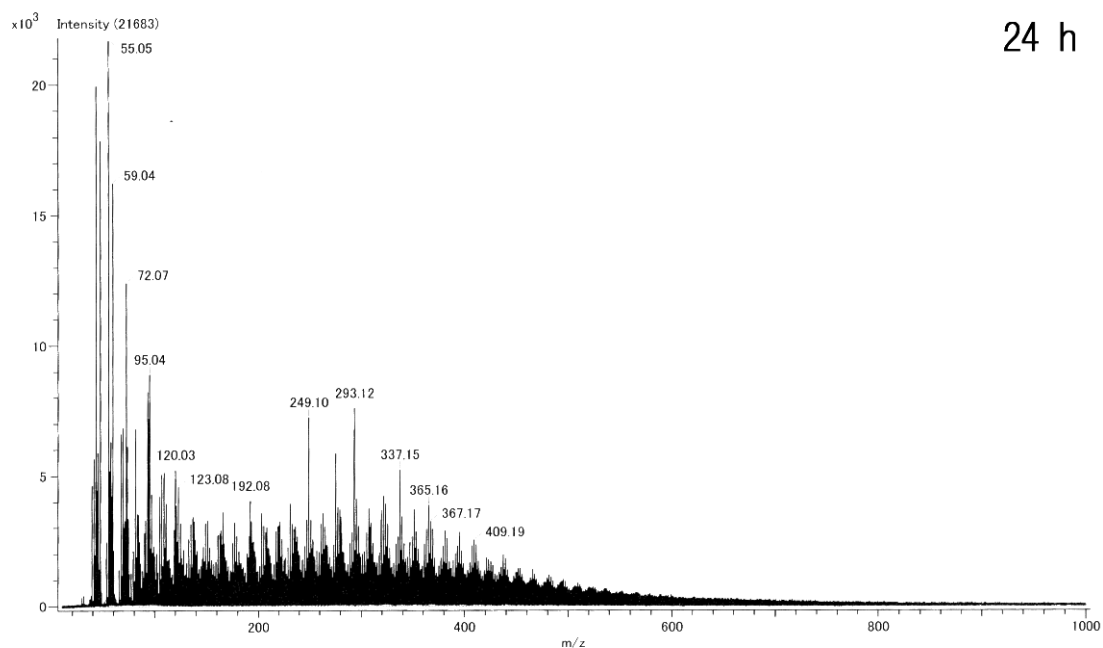


Figure S1. Time of flight mass spectral (TOF-MS) patterns of Fipronil during its degradation with $m/z = 0$ to 500 and up to $m/z = 1000$ up from 0 to 24 hours of UVC irradiation in aqueous media.